

**AMENDMENTS TO THE SPECIFICATION:**

On page 4, please replace the paragraph starting on line 32 with the following amended paragraph:

--Subsequently, a heat treatment of ceramic hybrid substrate 10 occurs, for example, at a temperature of about 100°C and for a period of about 30 minutes. This results in a silanization ~~(etherification)~~ (esterification) of ceramic surface areas 14. The resulting crosslinking is illustrated in Figure 5. Silicon attaches itself to the reactive groups, forming an Si-O-Si structure. Such silicon structures, as is conventional, excel by their chemically and thermally stable properties. Free hydroxyl groups (OH groups) as reactive groups react with the silicon-containing ~~educt~~ aduct, resulting in the formation of the Si-O-Si bond (siloxanes).--.